

Supporting Information

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Plasmonic Metasurfaces with High UV–Vis Transmittance for Photopatterning of Designer Molecular Orientations

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Supplementary Materials

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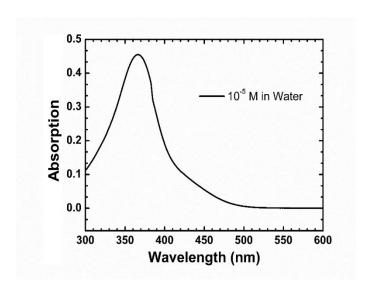


Figure S1 Absorption spectrum of SD-1 in water.

1. Absorption Spectrum of SD-1

The sulfuric dye 1 (SD-1) is a popular photoalignment material developed by Chigrinov et al.^[1,2] To measure the absorption spectrum of SD-1, we dissolve it in DI water at 10⁻⁵ M concentration. Fig. S1 shows the absorption spectrum measured by using a PerkinElmer UV-VIS photospectrometer.

2. Local Field Distribution for Parallelepiped Orientation $\theta = 30^{\circ}$

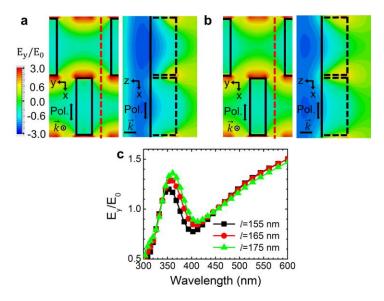


Figure S2 (a, b) Snapshots of the local electrical field distributions, at two resonant wavelengths, a) 375nm and b) 480 nm respectively. The incident polarization is along the y-axis, and l=180 nm, h=80 nm, p=220 nm, θ =30°. (c) Calculated local electric field enhancement as a function of wavelength at the top center of the gap between two neighboring parallelepipeds. Here p, h and θ are fixed at 220 nm, 80 nm and 30° respectively.

3. Plasmonic Lattice Resonance

With the couple dipole (CD) approach, the parallelepipeds can be treated as electrical dipoles. For the i-th parallelepiped at position r_i , the dipole moment can be expressed as: $\mathbf{P}_i = \alpha_0 \cdot \mathbf{E}_i$, where α_0 is the polarizability.^[3,4] The electric field acting on the dipole P_i equals the sum of the incident electrical field and the electrical fields generated by the other parallelpipeds:

$$E_i = E_0 + \sum_{j=1}^{\infty} \frac{e^{ik\boldsymbol{r}_{ij}}}{\boldsymbol{r}_{ij}^3} \{k^2 \boldsymbol{r}_{ij} \times (\boldsymbol{r}_{ij} \times \boldsymbol{P}_j) + \frac{1 - ik\boldsymbol{r}_{ij}}{\boldsymbol{r}_{ij}^2} \times [\boldsymbol{r}_{ij}^2 \boldsymbol{P}_j - 3\boldsymbol{r}_{ij}(\boldsymbol{r}_{ij} \cdot \boldsymbol{P}_j)]\}$$

 E_0 is the incident field. When the incident wave vector is perpendicular to the plane of the diple arrays, the electrical fields on different dipoles are the same, say $E_i = E_{total}$. Then all are equal, i.e. $P_i = \alpha_0 \cdot E_{total}$.

$$E_{total} = E_0 + \sum_{i \neq j} \left[\frac{(1 - ikr_{ij})(3cos^2\theta_{ij}e^{ikr_{ij}})}{r_{ij}^3} + \frac{k^2sin^2\theta_{ij}e^{ikr_{ij}}}{r_{ij}} \right] (\alpha_0 \cdot E_{total})$$

In this formula, θ_{ij} is the angle between the vector r_{ij} and the electrical direction. By defining a retarded dipole sum S(k):^[3-5]

$$S(k) = \sum_{i \neq j} \left[\frac{(1 - ikr_{ij})(3cos^2\theta_{ij}e^{ikr_{ij}})}{r_{ij}^3} + \frac{k^2sin^2\theta_{ij}e^{ikr_{ij}}}{r_{ij}} \right]$$

the dipole moment ${\pmb P}_{\rm i}$ can be expressed as ${\pmb P}_i = \alpha_{cluster} \cdot {\pmb E}_0$, where

$$\alpha_{cluster} = \frac{\alpha_s}{1 - \alpha_s S}$$

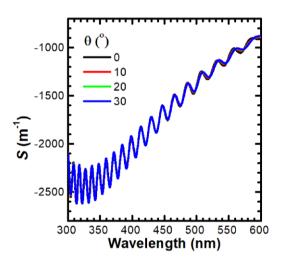


Figure S3 Calculated S parameter as a function of wavelength and orientational angles of parallelepipeds.

A resonance emerges when $Re(1 - \alpha_s S) = 0$, and the resonant frequency is determined by the real part of the S parameter. Since the parallelepipes are positioned in a triangular lattice, we only need to study the cases with θ varied between 0° and 30° . We calculated the S-parameter by summing over r_{ij} within a distance of 50p. The numerical results shown in Figure S2 indicate that the variations of θ impacts little on S. As a result, the frequency of the lattice resonance is insensitive to θ .

4. Projection Photopatterning System

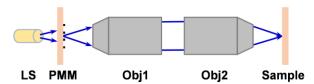


Figure S4 Schematic setup for the projection photopatterning based on the PMM. LS: white non-polarized light source; Obj1: imaging objective; Obj2: projection objective. The sample substrate is coated with a thin layer of photoalignment material such as SD-1.

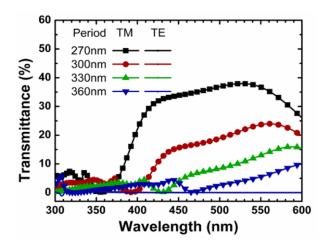


Figure S5 Simulated transmission spectra for plasmonic metamasks based on rectangular nanoapertures. The length and width of the rectangular nano-apertures are fixed at 220 and 100 nm.

5. Transmission Spectra of the Nanoaperture-Based Plasmonic Metamasks

Here we present simulation results for the optical transmission spectra of the plasmonic metamasks based on rectangular nanoapertures developed in our prior work. ^[6] The optical efficiency is almost negligible in the UV wavelength range where the absorption bands of the SD-1 and PAAD-22 are located.

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